# SLOVENSKI STANDARD

### SIST EN 60749-35:2007

januar 2007

Polprevodniški elementi - Mehanske in klimatske preskusne metode - 35. del: Akustična mikroskopija za elektronske komponente v plastičnih okrovih (IEC 60749-35:2006)

(istoveten EN 60749-35:2006)

Semiconductor devices - Mechanical and climatic test methods - Part 35: Acoustic microscopy for plastic encapsulated electronic components (IEC 60749-35:2006)

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<u>SIST EN 60749-35:2007</u> https://standards.iteh.ai/catalog/standards/sist/3e216c6b-b5b6-4659-8ad4-3aa509dbb065/sist-en-60749-35-2007

ICS 31.080.01

Referenčna številka SIST EN 60749-35:2007(en)

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### **EUROPEAN STANDARD**

### EN 60749-35

# NORME FUROPÉENNE **EUROPÄISCHE NORM**

September 2006

ICS 31.080.01

English version

### Semiconductor devices -Mechanical and climatic test methods Part 35: Acoustic microscopy for plastic encapsulated electronic components

(IEC 60749-35:2006)

Dispositifs à semiconducteurs -Méthodes d'essais mécaniques et climatiques Partie 35: Microscopie acoustique

pour composants électroniques

à boîtier plastique (CEI 60749-35:2006) Teh STANDARD Pder Elektronik (IEC 60749-35:2006)

Halbleiterbauelemente -Mechanische und klimatische Prüfverfahren Teil 35: Ultraschallmikroskopie für kunststoffverkappte Bauelemente

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#### SIST EN 60749-35:2007

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This European Standard was approved by CENELEC on 2006-09-01. CENELEC members are bound to comply with the CEN/CENELEC Internal Regulations which stipulate the conditions for giving this European Standard the status of a national standard without any alteration.

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## **CENELEC**

European Committee for Electrotechnical Standardization Comité Européen de Normalisation Electrotechnique Europäisches Komitee für Elektrotechnische Normung

Central Secretariat: rue de Stassart 35, B - 1050 Brussels

#### **Foreword**

The text of document 47/1863/FDIS, future edition 1 of IEC 60749-35, prepared by IEC TC 47, Semiconductor devices, was submitted to the IEC-CENELEC parallel vote and was approved by CENELEC as EN 60749-35 on 2006-09-01.

The following dates were fixed:

 latest date by which the EN has to be implemented at national level by publication of an identical national standard or by endorsement

(dop) 2007-06-01

 latest date by which the national standards conflicting with the EN have to be withdrawn

(dow) 2009-09-01

#### **Endorsement notice**

The text of the International Standard IEC 60749-35:2006 was approved by CENELEC as a European Standard without any modification.

In the official version, for Bibliography, the following note has to be added for the standard indicated:

IEC 60749-20

iTen Harmonized as EN 60749-20:2003 (not modified).

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<u>SIST EN 60749-35:2007</u> https://standards.iteh.ai/catalog/standards/sist/3e216c6b-b5b6-4659-8ad4-3aa509dbb065/sist-en-60749-35-2007

# **NORME** INTERNATIONALE INTERNATIONAL **STANDARD**

CEI **IEC** 60749-35

> Première édition First edition 2006-07

Dispositifs à semiconducteurs - Méthodes d'essais mécaniques et climatiques -

#### Partie 35:

Microscopie acoustique pour composants rélectroniques à boîtier plastique

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Semiconductor devices - Mechanical and climatic test methods — https://standards.iteh.ai/catalog/standards/sist/3e216c6b-b5b6-4659-8ad4-

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Part 35:

Acoustic microscopy for plastic encapsulated electronic components

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CODE PRIX PRICE CODE

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#### INTERNATIONAL ELECTROTECHNICAL COMMISSION

# SEMICONDUCTOR DEVICES – MECHANICAL AND CLIMATIC TEST METHODS –

# Part 35: Acoustic microscopy for plastic encapsulated electronic components

#### **FOREWORD**

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International Standard IEC 60749-35 has been prepared by IEC technical committee 47: Semiconductor devices.

This first edition cancels and replaces IEC/PAS 62191 published in 2000, which was based on a Joint (IPC/JEDEC) Industry Standard. This edition constitutes a technical revision.

Part 24:

Part 25:

Part 26:

Part 27:

The text of this standard is based on the following documents:

FDIS	Report on voting
47/1863/FDIS	47/1877/RVD

Full information on the voting for the approval of this standard can be found in the report on voting indicated in the above table.

This publication has been drafted in accordance with the ISO/IEC Directives, Part 2.

IEC 60749 consists of the following parts, under the general title Semiconductor devices – Mechanical and climatic test methods:

Mechanical and climatic test methods:				
	Part 1:	General		
	Part 2:	Low air pressure		
	Part 3:	External visual inspection		
	Part 4:	Damp heat, steady state, highly accelerated stress test (HAST)		
	Part 5:	Steady-state temperature humidity bias life test		
	Part 6:	Storage at high temperature		
	Part 7:	Internal moisture content measurement and the analysis of other residual gases		
	Part 8:	Sealing iTeh STANDARD PREVIEW		
	Part 9:	Permanence of marking (Standards.iteh.ai) Mechanical shock		
	Part 10:	Mechanical shock		
	Part 11:	Rapid change of tempera <u>ture ⊤Two</u> zfluid-bath method		
	Part 12:	Vibration variable frequency g/standards/sist/3e216c6b-b5b6-4659-8ad4-		
	Part 13:	Salt atmosphere 3aa509dbb065/sist-en-60749-35-2007		
	Part 14:	Robustness of terminations		
	Part 15:	Resistance to soldering temperature for through-hole mounted devices		
	Part 16:	Particle impact noise detection (PIND)		
	Part 17:	Neutron irradiation		
	Part 18:	Ionizing radiation (total dose)		
	Part 19:	Die shear strength		
	Part 20:	Resistance of plastic-encapsulated SMDs to the combined effect of moisture and soldering heat		
	Part 21:	Solderability		
	Part 22:	Bond strength		
	Part 23:	High temperature operating life		

Accelerated moisture resistance - Unbiased HAST

Electrostatic discharge (ESD) sensitivity testing – Human body model (HBM)

Electrostatic discharge (ESD) sensitivity testing – Machine model (MM)

Temperature cycling

Part 28:	Electrostatic discharge (ESD) sensitivity testing – Charged device model (CDM) (under consideration)
Part 29:	Latch-up test
Part 30:	Preconditioning of non-hermetic surface mount devices prior to reliability testing
Part 31:	Flammability of plastic-encapsulated devices (internally induced)
Part 32:	Flammability of plastic-encapsulated devices (externally induced)
Part 33:	Accelerated moisture resistance – Unbiased autoclave
Part 34:	Power cycling
Part 35:	Acoustic microscopy for plastic encapsulated electronic components
Part 36:	Acceleration, steady state
Part 37:	Board level drop test method of components for handheld electronic products (to be published)
Part 38:	Soft error rate testing of electronic components (under consideration)
Part 39:	Measurement of moisture diffusivity and water solubility in organic materials used for semiconductor components (to be published)

The committee has decided that the contents of this publication will remain unchanged until the maintenance result date indicated on the IEC web site under "http://webstore.iec.ch" in the data related to the specific publication. At this date, the publication will be

reconfirmed,withdrawn,

### iTeh STANDARD PREVIEW

- replaced by a revised edition strandards.iteh.ai)
- amended.

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# SEMICONDUCTOR DEVICES – MECHANICAL AND CLIMATIC TEST METHODS –

# Part 35: Acoustic microscopy for plastic encapsulated electronic components

#### 1 Scope

This part of IEC 60749 defines the procedures for performing acoustic microscopy on plastic encapsulated electronic components. This standard provides a guide to the use of acoustic microscopy for detecting anomalies (delamination, cracks, mould-compound voids, etc.) reproducibly and non-destructively in plastic packages.

#### 2 Terms and definitions

For the purposes of this document, the following terms and definitions apply.

#### 2.1

#### A-mode

acoustic data collected at the smallest X-Y-Z region defined by the limitations of the given acoustic microscope

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NOTE An A-mode display contains amplitude and phase/polarity information as a function of time of flight at a single point in the X-Y plane. In this test method, A-mode is primarily used for focussing the acoustic microscope. See Figure 1.

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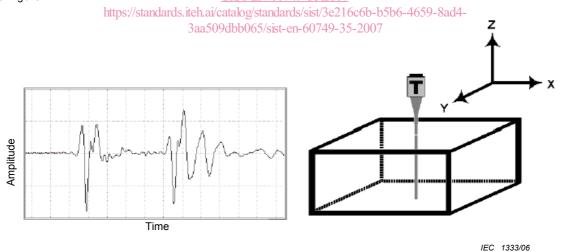


Figure 1 - Example of A-mode display

#### 2.2 B-mode

acoustic data collected along an X-Z or Y-Z plane versus depth using a reflective acoustic microscope. A B-mode scan contains amplitude and phase/polarity information as a function of time of flight at each point along the scan line

NOTE A B-mode scan furnishes a two-dimensional (cross-sectional) description along a scan line (X or Y). In this test method B-mode is used to provide cross-sectional acoustic information. When scanned, B-mode can be used to track the depth of a defect. See Figure 2.

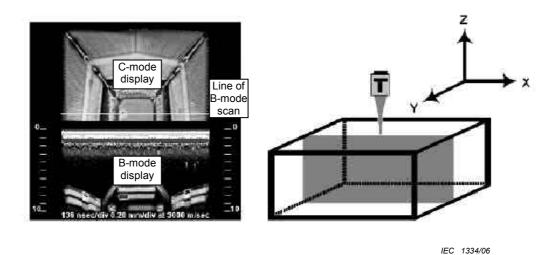


Figure 2 - Example of B-mode display (bottom half of picture on left)

# 2.3 back-side substrate view area

interface between the encapsulant and the back of the substrate within the outer edges of the substrate surface (refer to Annex A, type IV) A R D P R F V IF W

# 2.4 (standards.iteh.ai)

acoustic data collected in an X-Y plane at depth (Z) using a reflective acoustic microscope

NOTE 1 A C-mode scan contains amplitude and phase/polarity information at each point in the scan plane. A C-mode scan furnishes a two-dimensional (area) image of echoes arising from reflections at a particular depth (Z). See Figure 3.

NOTE 2 C-mode is the preferred mode for scanning devices to determine compliance to the criteria of IEC 60749-20.

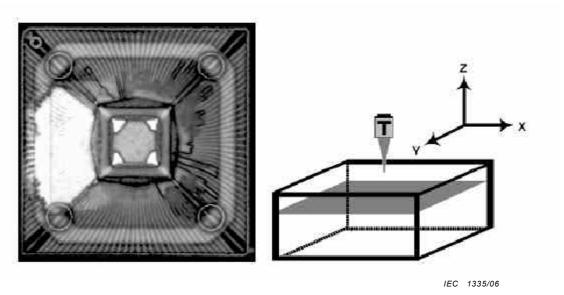


Figure 3 - Example of C-mode display